



## UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/177,814	10/23/1998	TERRY L. GILTON	353OUS(97-12	3621
75	90 02/06/2006		EXAMINER	
JOSEPH A WALKOWSKI			YANG, NELSON C	
TRASK BRITT & ROSSA P O BOX 2550			ART UNIT	PAPER NUMBER
SALT LAKE CITY, UT 84110			1641	
			DATE MAILED: 02/06/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

## **Advisory Action** Before the Filing of an Appeal Brief

Application No.	Applicant(s)		
09/177,814	GILTON, TERRY L.		
Examiner	Art Unit		
Nelson Yang	1641		

	Nelson Yang	1641	
The MAILING DATE of this communication appe	ars on the cover sheet with the	correspondence add	ress
THE REPLY FILED 09 January 2006 FAILS TO PLACE THIS A	PPLICATION IN CONDITION FOR	R ALLOWANCE.	
1.  The reply was filed after a final rejection, but prior to or on this application, applicant must timely file one of the follow places the application in condition for allowance; (2) a No a Request for Continued Examination (RCE) in compliance time periods:	the same day as filing a Notice of ving replies: (1) an amendment, af tice of Appeal (with appeal fee) in	Appeal. To avoid aba fidavit, or other evider compliance with 37 C	rce, which FR 41.31; or (3)
a) The period for reply expires 3 months from the mailing date b) The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire la Examiner Note: If box 1 is checked, check either box (a) or ( TWO MONTHS OF THE FINAL REJECTION. See MPEP 7)	dvisory Action, or (2) the date set forth ater than SIX MONTHS from the mailin b). ONLY CHECK BOX (b) WHEN THI	g date of the final rejecti	on.
Extensions of time may be obtained under 37 CFR 1.136(a). The date have been filed is the date for purposes of determining the period of exunder 37 CFR 1.17(a) is calculated from: (1) the expiration date of the set forth in (b) above, if checked. Any reply received by the Office later may reduce any earned patent term adjustment. See 37 CFR 1.704(b) NOTICE OF APPEAL	ension and the corresponding amount hortened statutory period for reply orig than three months after the mailing da	of the fee. The appropri	ate extension fee ce action; or (2) as
<ol> <li>The Notice of Appeal was filed on A brief in comp filing the Notice of Appeal (37 CFR 41.37(a)), or any exter a Notice of Appeal has been filed, any reply must be filed AMENDMENTS</li> </ol>	nsion thereof (37 CFR 41.37(e)), to	avoid dismissal of th	
<ol> <li>The proposed amendment(s) filed after a final rejection,</li> <li>(a) They raise new issues that would require further control (b) They raise the issue of new matter (see NOTE below)</li> </ol>	nsideration and/or search (see NO		ecause
(c) They are not deemed to place the application in bet appeal; and/or	ter form for appeal by materially re		the issues for
(d) They present additional claims without canceling a NOTE: (See 37 CFR 1.116 and 41.33(a)).			
<ul> <li>The amendments are not in compliance with 37 CFR 1.13</li> <li>Applicant's reply has overcome the following rejection(s)</li> </ul>		ompliant Amendment	(PTOL-324).
<ol> <li>Newly proposed or amended claim(s) would be al  non-allowable claim(s).</li> </ol>			_
7.  For purposes of appeal, the proposed amendment(s): a) how the new or amended claims would be rejected is provided the status of the claim(s) is (or will be) as follows: Claim(s) allowed:		ill be entered and an e	explanation of
Claim(s) allowed: Claim(s) objected to: Claim(s) rejected:			
Claim(s) withdrawn from consideration:  AFFIDAVIT OR OTHER EVIDENCE			
<ol> <li>The affidavit or other evidence filed after a final action, bu because applicant failed to provide a showing of good and was not earlier presented. See 37 CFR 1.116(e).</li> </ol>			
9. The affidavit or other evidence filed after the date of filing entered because the affidavit or other evidence failed to o showing a good and sufficient reasons why it is necessary	vercome all rejections under appe	al and/or appellant fai	ls to provide a
<ol> <li>The affidavit or other evidence is entered. An explanation REQUEST FOR RECONSIDERATION/OTHER</li> </ol>		•	
<ol> <li>The request for reconsideration has been considered bu <u>See Continuation Sheet.</u></li> </ol>	t does NOT place the application is	n condition for allowar	nce because:
<ul> <li>11. ☑ The request for reconsideration has been considered bu See Continuation Sheet.</li> <li>12. ☐ Note the attached Information Disclosure Statement(s).</li> <li>13. ☐ Other:</li> </ul>	(PTO/SB/08 or PTO-1449) Paper N	Vo(s).	
		John	
		LONG V. LE IVISORY PATENT EXA	

TECHNOLOGY CENTER 1600

Continuation of 11. does NOT place the application in condition for allowance because: applicant arguments are not persuasive. Applicant argues that Northrup et al [US 5,882,496] do not teach a detector fabricated on the substrate in communication with at least one of the porous region. The Office disagrees with this argument, as Northrup et al clear teach that the porous region defines an interface between two analysis devices (claim 10), and further teach that the porous silicon regions increases the surface area of thermopneumatic sensor-actuators (column 1, lines 55-65). Applicant's arguments regarding claim 7 that Northrup et al fail to teach a reaction region situated along a length and contiguous with a porous region is not found persuasive either, as Northrup et al specifically teach that the reactor is defined by a porous silicon section (column 7, lines 20-25).

Applicant's arguments regarding the written description rejection is also not found persuasive. Although claims currently recite porous regions comprising the same material as the substrate, nowhere in the disclosure can support for the limitation be found, specifically that the porous regions and the substrate comprise the same material. Rather the support that applicant cites merely provides support for the much narrower limitation of a silicon support with porous silicon regions.